

# **Notice of References Cited**

Application/Control No.

09/600,546

Applicant(s)/Patent Under  
Reexamination  
CHAPPERT ET AL

Examiner

Martin J Angebrannndt

Art Unit

1756

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## **U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification	
	A	US-4551908 ✓	11-1985	Nagasawa et al.	29	571
	B	US-4600488 ✓	07-1986	Imura et al.	204	298
	C	US-				
	D	US-				
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	K	US-				
	L	US-				
	M	US-				

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	N	62-297458	12-1987	Japan	****	--	--
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## **NON-PATENT DOCUMENTS**

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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.

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	G	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

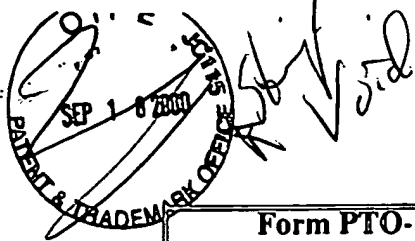
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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	2773632	07-1999	France	Chappert et al.	***
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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Copy of Specification denoted WO 99/35657 in upper left and 1 in upper right.
	V	Copy of specification denoted 2 in upper right hand corner.
	W	
	X	<b>BEST AVAILABLE COPY</b>

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Form PTO-1449 (Modified)	Atty Docket No. 15675.P322	Serial No. 09/600,546
List of Patents & Publications Statement	Applicant(s): C. Chappert	
(Use several sheets if necessary)	Filing Date: 7/12/00	Group No. 1756

## U.S. PATENT DOCUMENTS

Exam. Initials	Document Number	Date	Name	Class	Sub-class	Filing Date (if appropriate)
	AA					
	AB					
	AJ					
	AK					

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Exam. Initials	Document Number	Date	Country	Class	Sub-class	Translation Yes No
UA	AL JP0129699	11/1999	Japan	-	-	X
	AQ					

## OTHER ART (Including Title, Author, Date, Pertinent Pages, etc.)

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UA	AR Xiao J Q. et al.: "Effects of ar-Ion implantation and annealing on structural and magnetic properties of CO/PD multilayers" Journal of applied Physics, vol. 76, no. 10, part 02 11/15/94, pages 6081-6083
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UA	AV Schelp L. F. et al.: "Structural and Magnetic Behavior of AR+-Implanted Co/PD Multilayers: Interfacial Mixing" Journal of Applied Physics vol. 75, no. 10, part 01, May 15, 1994

Examiner:                     Date Considered:                     

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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